Best from two worlds: SiOPlas[™] primary containers



Coating Deposition Process

Plasma Enhanced Chemical Vapor Deposition - PECVD



Barrier Coating System Architecture



Barrier Coating System Surface Characteristics

• Key Surface Attributes:

- Covalently bonded barrier coating system
- Hydrophobic organosiloxane surface
- Inert chemically resistant coating

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- Resists pH shift
- Low Si dissolution
- No metal ion leachables



"Organo-siloxane"

Product Attributes and Benefits

Product purity

- No silicone oil
- Outstanding chemical resistance, protects sample integrity
- Effective block of E&L due to barrier coating
- Protection against oxygen transmission
 - Oxygen transmission rates rival that of glass containers
- Package durability
 - Supports a wide range of temperatures
 - Compatible with many sterilization methods (EO, Ebeam, Steam)

• Eliminates risk for breakage

- Eliminates shattering of glass throughout supply chain
- Reduces end-user complaints and recalls
- Tight dimensional control
 - Products are all precision-molded
- Customized surface characteristics
 - Hydrophobic or hydrophilic surface characteristics
- Consistency and reliability
 - Advanced technologies to assure coating of every product shaped
 - Six-Sigma quality performance



=differences to plain COP containers

Fully automated coating lines: Vial and syringe coating



- Process incorporates real time monitoring of all key process variables and 100% in line inspection for critical to quality attributes.
- State-of-the art visual particle control systems: online inspection of empty vials: 50µm

Fully automated modular coating lines



- All coating operations take place in one station without moving the part
- Scale-up to 8-up configuration
- Plug and Play manufacturing concept to allow for seamless scale-up / maintenance with minimized downtimes